

Printable Thermoelectric Device

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Printable Thermoelectric Device

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Abstract. We have fabricated a printed flexible thermoelectric generator using composite of Bi₂Te₃ and PEDOT:PSS. The nano-structured thermoelectric thin film was made by printing method and the paste for printing was prepared by mixing nano-particles of Bi₂Te₃, PEDOT:PSS and polyamic acid as a additives. The non-dimensional figure of merit was 0.2 for p-type composite thin film at room temperature due to the low thermal conductivity. The interfacial thermal resistance between Bi₂Te₃ and PEDOT:PSS was measured to understand the low effective thermal conductivity of the printed thermoelectric composite. The measured organic-inorganic interfacial thermal resistance is in the order of 10⁻⁷ (m²·K)/W which is about 10 times higher than the inorganic-inorganic interfacial thermal resistance. The extremely low thermal conductivity of the printed thermoelectric materials can be explained by high interfacial resistance between inorganic-organic materials.

1. Introduction

The electricity can be directly generated from thermal energy by thermoelectric conversion even at room temperature. On the other hand, thermal energy can be transferred for cooling by applying the electricity to the thermoelectric material. The thermoelectric efficiency is the function of the nondimensional figure of merit, ZT (Z=σS²/λ, S: Seebeck coefficient (V/K), σ: Electrical conductivity (S/m), λ: Thermal conductivity (W/m K), T: Temperature, (K)) [1]. Bismuth telluride (Bi₂Te₃) has shown one of the best performance for thermoelectric generator since its discovery [2]. However, transforming into flexible, printable and wearable electronics is challenging task while maintaining desired high ZT. To maintain a high ZT by lowering thermal conductivity, nano-structuring of a material has been reported from the view point of heat conduction [3]. The thermal energy is transported in solids by lattice vibration, and the mechanisms can be understood by phonon transport [4]. The heat conduction is diffusive when the characteristic size is much larger than mean free path of phonons. However, the ballistic phonons transport will occurs when the characteristic size is shorter than the mean free path of phonons. Thermal conductivity is no longer constant physical property under the ballistic phonon transport [5]. The figure of merit can be enhanced by using the difference between phonons and electrons mean free path [6]. The mean free path of electrons is mostly shorter than the mean free path of phonons. The phonon transport can be suppressed by nano-structures, such as nano-porous [7,8], nano-composite [9], nano-crystalline [10], nano-wire [6] etc. to enhance the value of ZT.

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In this manuscript, we present the flexible thermoelectric electric module prepared by printing method and an understanding of thermal boundary resistance at the organic-inorganic interface which plays an important role in the reduction of effective thermal conductivity to enhance the figure of merit.

2. Interfacial Thermal Boundary Resistance Evaluation

Interfacial thermal resistance is determined using a differential 3\omega method [11]. In this method, the value of thermal resistance can be obtained from the temperature rise (ΔT_{AC}) (Expressed by equation1) due to Joule heating, generated by applying an alternating current (I=I₀cos(ωt)) in a thin aluminum line wire on the sample. This aluminum line works as a heater and thermometer. $\Delta T_{AC} = \frac{P}{\pi \lambda_s} \left\{ \frac{1}{2} ln \left(\frac{D_s}{b^2} \right) + 0.923 - \frac{1}{2} ln (2\omega) \right\} + \frac{P}{2b} R_f$

$$\Delta T_{AC} = \frac{P}{\pi \lambda_s} \left\{ \frac{1}{2} \ln \left(\frac{D_s}{b^2} \right) + 0.923 - \frac{1}{2} \ln(2\omega) \right\} + \frac{P}{2b} R_f \tag{1}$$

where, λ_s is the thermal conductivity of the substrate, D_s is the thermal diffusivity of the substrate, R_f is the thermal resistance of the thin film sample, P is the power per unit length applied to the thin aluminum line wire, and 2b is the width of the aluminum wire. The first term of the equation (1) reflects the thermal physical property of the substrate while the second term is the contribution from thin film. In our analysis, sample is linear connections of resistance in the series where we can simple subtract the resistance equation to get the value of interfacial resistance. Applying the same analysis, the thermal resistance of the thin film can be written as equation (2) by subtracting the temperature change (equation (1)) for the substrate and the thin film on the same substrate (substrate + thin film).

$$R_f = \frac{\Delta T_f - \Delta T_s}{I_0^2 R_0} A \tag{2}$$

where, ΔT_f is the temperature rise of the sample (substrate + thin film), ΔT_s is the temperature rise of the substrate, A is the surface area of the aluminum thin wire, and R₀ is the resistance of this aluminum wire. The solution of equations (1) and (2) can be written as equation (3) where δ is the thickness of the thin film and λ is the thermal conductivity of the thin film. We can estimate the value of interfacial thermal resistance (R_i) from the y-intercept of the plot of film thickness and thermal resistance [12].

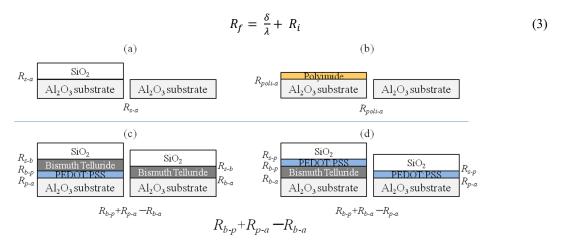


Fig.1: Schematic for thermal boundary resistance (a) for SiO₂-Al₂O₃ boundary resistance, (b) for Polyimide-Al₂O₃ boundary resistance, (c) and (d) for Bi₂Te₃-PEDOT:PSS boundary resistance.

Figure 1 shows a schematic diagram of the series of samples. We subtract the resistance connected in series to get the organic-inorganic interfacial boundary resistance. Alumina was used as a substrate due to its relatively high thermal conductivity. We calculated thermal boundary resistance at the Journal of Physics: Conference Series 1407 (2019) 012057

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interface of SiO₂ and alumina substrate (R_{s-a}) by subtracting measured thermal resistance of SiO₂ thin film (R_s) and alumina substrate (R_a). Similarly, we calculated thermal boundary resistance at the interface of polyimide and alumina substrate (R_{poli-a}) (Fig.1 (a) and (b)). In a simple notation, we used suffix *poli* for polyimide, *a* for an alumina substrate, and *s* is SiO₂ thin film. Further, the interfacial thermal boundary resistance of Bi_2Te_3 -PEDOT:PSS was calculated by two cases. In the first case, the thickness of PEDOT: PSS was varied while the thickness of SiO₂ and Bi_2Te_3 were kept constant (Fig 1 (c)). Thermal boundary resistance at the interface of Bi_2Te_3 and PEDOT:PSS ($R_{b-p}+R_{p-a}-R_{b-a}$) was obtained in Fig. 1 (c). The suffix *p* indicates PEDOT:PSS, and *b* indicates Bi_2Te_3 . In case two, the thickness of Bi_2Te_3 was varied while keeping the thickness of PEDOT:PSS and SiO₂ constant (Fig 1 (d)). The interfacial thermal resistance $R_{b-p}+R_{b-a}-R_{p-a}$ was obtained (Fig 1 (d)). Interfacial thermal resistance $R_{b-p}+R_{b-a}-R_{b-a}$ and $R_{b-p}+R_{b-a}-R_{p-a}$.

3. Experimental Detail

We fabricated organic-inorganic interface of PEDOT:PSS-Bi₂Te₃, the organic-inorganic interface of the polyimide-alumina substrate and the inorganic-inorganic interface of the SiO₂-alumina substrate. PEDOT: PSS, Bi₂Te₃, polyimide, and SiO₂ thin films were prepared on alumina substrate for respective interface thermal resistance measurement. A polyimide film was prepared by spin coating. Thick polyamic acid solution (16 wt %) (Sigma Aldrich) was diluted in N-methyl-2-pyrrolidone. It was stirred for 10 mins to achieve a homogeneous solution to be used in spin coating. The thickness of polyimide film is about 500, 700, 1,000 and 1,800 nm. PEDOT:PSS thin films are also spin coated on plasma treated alumina substrate. The rotation speed was changed to produce 60 and 105 nm thin films. Bi₂Te₃ is used as an inorganic thermoelectric material for organic-inorganic interface. The thin film of Bi₂Te₃ of thickness 100, 330, and 560 nm was deposited by arc plasma technique in a vacuum chamber at the base pressure of 5.0×10^{-3} Pa on alumina substrate [13]. The deposition was carried out by performing a predetermined number of discharges at a discharge voltage of 80 V and a discharge interval of 1 second. The growth rate is about 0.8 nm per discharge. Thermal conductivity of the thin films is measured by 300 technique. We deposited thin aluminum metal line wire by thermal deposition technique using a shadow mask in a vacuum chamber (5.0 × 10⁻³ Pa) to serve as a heater and temperature sensor. SiO₂ was deposited as an insulator in between sample and aluminum wire by ebeam evaporation technique.

4. Results and Discussion

Figure 2 shows thin film of composite of Bi₂Te₃ and PEDOT:PSS on a flexible substrate. There are many interfaces between organic and inorganic materials. The measured thermal conductivity was 0.2-0.3 W/(m·K)[14]. It was much lower than the evaluated value by using conventional thermal conductivity model for composite. We summarize the result of thermoelectric organicinorganic interface in figure 3. The temperature rise of PEDOT:PSS on alumina substrate is shown in Fig 3 (a) while thickness of Bi₂Te₃ and SiO₂ films are kept constant about 400 and 800 nm respectively. The temperature rises with increase in thickness. The thermal resistance variation depending on the thin film thickness of PEDOT: PSS are shown in Fig 3 (b). The thickness of PEDOT: PSS thin film was varied from 50 nm to 100 nm while thickness of Bi₂Te₃ and SiO₂ films is kept constant about 400 and 800nm respectively. The thermal conductivity of PEDOT: PSS was 0.34 ± 0.13 W/(m·K) (literature value 0.3 W/(m·K) [15]).

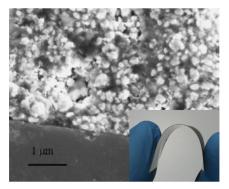


Fig.2: SEM cross-sectional image of a printed Thin film of composite of Bi₂Te₃ and PEDOT:PSS. Inset: Thin film of composite of Bi₂Te₃ and PEDOT:PSS on a flexible substrate.

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The interfacial thermal resistance $R_{b\text{-}p}+R_{p\text{-}a}-R_{b\text{-}a}$ obtained from the y-intercept of Fig. 3 (b) was $1.9 \pm 0.4 \times 10^{-7}$ (m²·K)/W. The temperature rise of Bi_2Te_3 on the alumina substrate of Fig.3 (c), while PEDOT: PSS (100 nm) and SiO_2 (2000 nm) are kept constant. The obtained thermal resistance and the film thickness of Bi_2Te_3 are shown in Fig 3 (d). The thermal conductivity of Bi_2Te_3 was 1.3 ± 0.13 W/(m·K) (literature value 1.5 W/(m·K) [1]). The interfacial thermal resistance $R_{b\text{-}p}+R_{b\text{-}a}-R_{p\text{-}a}$ obtained from the y-intercept of Fig. 3 (d) was $2.6 \pm 2.0 \times 10^{-8}$ (m²·K)/W. The Bi_2Te_3 -PEDOT: PSS interface thermal resistance $R_{b\text{-}p}$ was about $1.1 \pm 1.2 \times 10^{-7}$ (m²·K)/W.

The thermal conductivity of polyimide thin films is about $0.6 \pm 0.2~W/(m\cdot K)$ (literature value $0.2~W/(m\cdot K)$ [16]). The thermal conductivity of polyimide is closely related to the microstructure, and further discussion on the difference between the literature value and the experimental value is under investigation. The interfacial thermal resistance R_{poli-a} of the polyimide- alumina substrate interface is about $4.3\pm3.4\times10^{-7}~(m^2\cdot K)/W$. The measured thermal conductivity of SiO_2 is about $1.02\pm0.4~W/(m\cdot K)$ (literature value $0.7~W/(m\cdot K)$ [17]). The interfacial thermal resistance R_{s-a} of the SiO_2 -alumina substrate interface is about $4.1~\pm~4.0\times10^{-8}~(m^2\cdot K)/W$. Our result shows that the organic-inorganic interfacial thermal resistance is 10~times higher than the inorganic-inorganic interfacial thermal resistance.

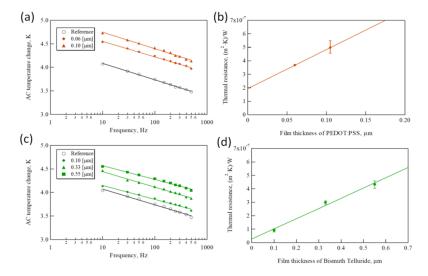


Fig.3: (a) AC temperature change and (b) thermal resistance of multilayered thin films with different thickness of PEDOT:PSS while thickness of Bi₂Te₃ and SiO₂ films are kept constant about 400 and 800 nm respectively, (c) AC temperature change and (d) thermal resistance of multilayered thin films with different thickness of Bi₂Te₃ while the thickness of PEDOT:PSS and SiO₂ films are kept constant about 100 and 2000 nm respectively.

5. Summary

We have successfully fabricated a printed flexible thermoelectric thin film using a composite of an organic and inorganic hybrid (Bi₂Te₃, PEDOT:PSS). Our result shows the value of ZT for the composite of Bi₂Te₃, PEDOT:PSS was 0.2 for p-type at room temperature. Further, the interfacial thermal resistance was determined in the series of samples such as alumina substrate-polyimide thin film, alumina substrate-SiO₂ thin film, alumina substrate-PEDOT: PSS-Bi₂Te₃-SiO₂ thin film, alumina substrate-Bi₂Te₃-PEDOT: PSS-SiO₂ thin films. We found that the thermal resistance of the alumina substrate-polyimide interface was $4.3\pm3.4\times10^{-7}$ (m²·K)/W, the interface thermal resistance of the alumina substrate-SiO₂ interface was $4.1\pm4.0\times10^{-8}$ (m²·K)/W. The thermal resistance of the organic-inorganic interface is 10 times larger than the thermal resistance of the inorganic-inorganic interface,

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and it is found that the thermal resistance is great among materials having completely different properties. The thermal resistance of the Bi_2Te_3 -PEDOT: PSS interface was $1.1\pm0.3\times10^{-7}$ (m²·K)/W. We believe it will serve as a new path for establishing a method to predict heat conduction in organic-inorganic hybrid system.

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